# OPAL-EC: edge-coupling wafer-level test station

AUTOMATED TEST STATION FOR INTEGRATED PHOTONICS

Accurate, repeatable, flexible, fast testing of photonic integrated circuits (PIC) with traceable results



## **KEY FEATURES**

Complete PIC testing platform with production-grade hardware

Best-in-class repeatability of optical probe and base motion systems

Industry first multiport edge-coupling testing at wafer level

Preparation, automated execution and data processing within one software suite

Wafer, stretch-tape, multiple dies or bar testing with the same station

Flexible design with repositionable optical and RF/DC probes

Compatible up to 300 (mm) / 12-in wafers

### APPLICATIONS

R&D to high-volume multisite production for known-good-die identification

Opto-electronic testing on integrated photonics platforms: silicon photonics, indium phosphide, III-V, polymer, heterogeneous

Application-agnostic: telecom and datacom transceivers, quantum, LIDAR, sensors, Al



## **OPAL-EC PLATFORM**

The OPAL-EC edge-coupling wafer-level test station provides industry-leading performance for integrated photonics characterization with accurate, repeatable, flexible and fast hardware. The PILOT software suite enhances the OPAL-EC hardware capabilities by transforming the hardware into an automated testing station and a source of quality measurements that can be digested into actionable data. The complete suite of applications is a platform that supports the full test-and-measurements flow and help users to become more data-driven. Combined with EXFO's advanced optical measurements capabilities and open to any third-party instrument, this complete platform is the ideal PIC testing solution.



Figure 1. EXFO's platform for wafer-level PIC testing, with OPAL-EC test station, PILOT software, and EXFO's leading solutions for optical characterization of PIC. Third-party instruments can be added and controlled by PILOT.

The station's hardware consists of an ultra-repeatable 4-axis motion system wafer positioning stage, allowing 105° rotation with a chuck to hold up to 12-in (300 mm) wafers with thermal control as an option. Adapter plates enable tests for single dies, bars and multiple dies making it one station to fit all form factors. The station can accommodate up to four probing heads with a choice of optical or electrical probes. It also includes high-resolution, in-line brightfield top vision system and telecentric side vision systems. The system includes dedicated license for the PILOT software suite, installed on an industrial rackmount computer.

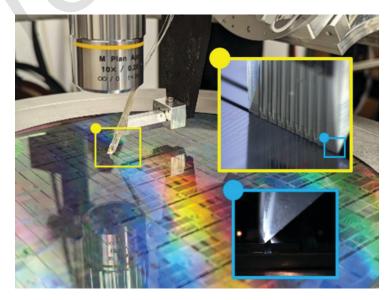


Figure 2. Edge-coupling within trench on wafer using a special fiber array and the OPAL-EC-300 station.



An industry-first: the station's state-of-the-art components enable fully automated, highly repeatable, multi-port, optical edgecoupling alignment at the wafer-level through trench coupling. This accuracy level disrupts the typical reliance on surface grating coupler as additional proxies for die screening at the wafer-level. This, in turn, allows for testing the complete circuit, including the production ports that will be used for packaging, much earlier in the production chain, which eliminates costly steps and increases global yield and circuit performances.

The same test station can also swiftly be reconfigured in-situ and used for surface-coupling alignment.



Figure 3. Re-testing the same circuits with a single OPAL-EC station over the process chain: from wafer, to singulated dies on stretch-tape, to multiple depopulated dies on a plate adapter. Here, with optical surface coupling and DC probe.

The OPAL-EC station is part of the OPAL family of test stations dedicated to PIC testing. The family includes a surface-couplingonly station, OPAL-SC and a single-die station, OPAL-SD, all powered by the PILOT software.

## PILOT AUTOMATION SOFTWARE

PILOT is a software platform that orchestrate the complete flow of PIC test and measurement: (i) test preparation, (ii) execution of fully automated navigation, alignment and measurements at a high throughput and (iii) analysis and data management of the results.



Figure 4. OPAL test stations and PILOT software automates PIC testing with powerful, scalable features, utilizing multiple applications linked to a collaborative database for advanced data analysis and AI.



#### Powerful and scalable

From software architecture to implementation, PILOT is designed for scalability in time and volume and helps implement best practices. It streamlines automation of tasks (preparation, data analysis, reporting) and measurements (navigation, alignment, instrument control) to increase effectiveness. The software is composed of multiple applications, each designed for its specific task, with de-coupled concepts and responsibilities.

#### **Database benefits**

Underlying all applications, the software is linked to a database (cloud-based or on-premises), that acts as a data repository for all of the elements (results and experimental conditions, station configuration, test definition, component definition, drivers, python scripts). PILOT enables multi-users, multi-site collaboration with a shared common workspace of the data. The database is relational, traceable and scalable to high volume, making the system natively compatible and designed to support advanced data analysis, artificial intelligence and business intelligence tools through built-in tools or by interoperability.



Figure 5. PILOT software suite: Prepare – Execute – Analyze with a single software.



## **OPAL-EC PLATFORM COMPONENTS**

A test station consists of the OPAL-EC main system station with PILOT software. Probing heads (optical and electrical) types and number of units should be added for a complete system, depending on the requirements. The OPAL-EC comes in two different options of sizes, either to accommodate wafers up to 200 mm (OPAL-EC-200) or up to 300 mm (OPAL-EC-300). Other options are available to accommodate more specific needs, such as a thermal chuck.

	COMPONENTS			
OPAL-EC MAIN SYSTEM	Chuck		Aluminum surface, ground polished, ambient temperature, chuck with 1 x vacuum zone. Electrical surface connection options.	- TCH: Thermally controlled chuck with heating and cooling capabilities, with range from 0 °C to 200 °C, 4 vacuum zones
	Wafer positioning base stage		High accuracy, 4 degrees of freedom wafer positioning with possibility to rotate a wafer by 105°.	- 200: 200 mm (8-in) or - 300: 300 mm (12-in) diameter chuck and XY travel range
	Vision system		Top high-resolution video system with 10X magnification using in-line coaxial illumination and 2.9 MP color camera on XYZ manual adjustment.	
	vision system		Magnetic toggleable, side view 2.9 MP color camera with 3X telecentric magnification on XY manual adjustment.	
	Additional accessories	2	Industrical rackmount PC and accessories (KMV), two 27-in monitors.	<ul> <li>Free-standing workstation</li> <li>Top enclosure</li> </ul>
	PILOT software dedicated license	1 Enclose	Full software suite for complete test and measurement flow of PIC. Automation and control of test station, instruments and data for absolute traceability and reliability of results that are report-ready and Al-ready.	- Additionnal floating licenses available, for multi-user collaboration from anywhere
PROBES <sup>a</sup>	Electrical head		4-axis manual electrical probe positioners. Fine alignment and long travel range. Probe holders compatible with most DC and RF probes.	<ul> <li>PRE-00: Manual, 50 mm range</li> <li>PRE-MO: Motorized, 25 mm range, 200 nm resolution</li> </ul>
	Optical (PRO-XX)	and the second s	Motorized 6-axis nanometer-precision and piezo-based hexapod for precise and fast operation for edge coupling as well as surface coupling. Features virtual pivot point, ideal for optimization of injection angle during automated coupling. Includes a clamp that fits most fiber arrays and a slider and manual screws concept to toggle between engaged/ disengaged positions.	- Other optical head options available (contact an EXFO representative)

a. Optical probes (fiber array, fiber) and electrical probes (DC, RF) are not included in the system. If these components are required, please contact an EXFO representative.



## **BUILD YOUR STATION CONFIGURATION**

The OPAL platform provides a flexible test environment to build a custom configuration, that can be modified at any time based on your needs and lowers design-for-test (DfT) requirements. Optical and electrical probes can be positioned around the wafer or die under test in any cardinal orientation (East/West/North/South), up to a total of four.

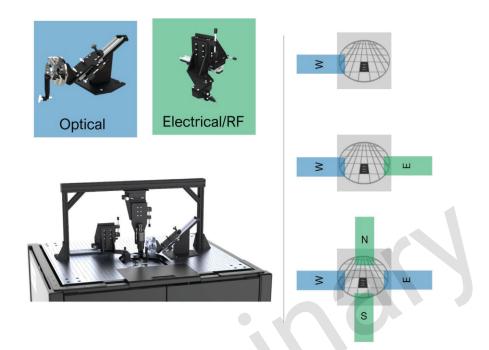


Figure 6. Reconfiguration of OPAL-EC for optical and electrical heads at any time for fast re-tooling.

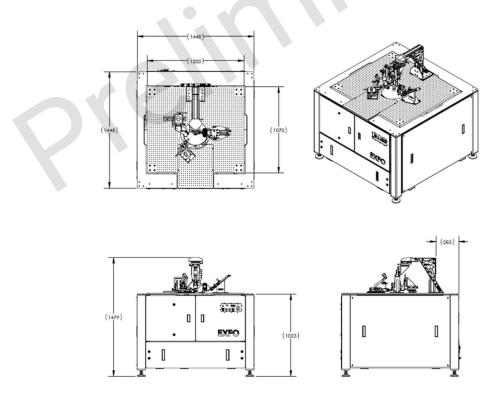


Figure 7. Technical drawing of the OPAL-EC-300 main system with dimensions in millimeters. Shown here with one (1x) PRO-P60 optical head and one (1x) PRE-00 manual electrical head. Not shown are the included the industrial rackmount PC, and the IT Kit (monitors, keyboard, mouse). Not shown are the chiller and the thermal chuck controller included with the (-TCH option). Non-final.



# **SPECIFICATIONS**

Option name		OPAL-EC-200	OPAL-EC-300
	Travel range (mm)	200	300
	Resolution (µm)	0.003	
	Accuracy (µm)	0.5	0.75
XY Axis	Bi-directional repeatability (µm)	0.1	
	Maximum process speed (mm/s)	100	
	Orthogonality arcsec	1	
	Motor type	Direct-drive linear motors, noncontact encoder	
	Travel range (mm)		5
	Resolution (µm)	0.0008	
Z Axis	Accuracy (µm)	1	.5
(Height)	Bi-directional repeatability (µm)	0	.3
	Maximum speed (mm/s)		4
	Motor type	Direct-drive brush	nless linear motor
	Travel range	10	5°
	Resolution	0.36 arcsec; 0.0001 °	
Rz Axis (Wafer rotation)	Accuracy	80 arcse	ec; 0.02 °
	Repeatability	3 arcsec	0.0008 °
	Maximum speed (rpm)	60	00
	Motor type	Direct-drive brushless rotary	/ motor, mechanical bearing

СНИСК				
Option name	ТА	тн	тсн	
Range (°C) ª	Ambient	Ambient - 200	0 - 200	
Resolution (°C)		0.01		
Stability (°C)		±0.05°C (>25°C)	±0.05°C (>25°C) and ±0.1°C (<25°C)	
Heating rate (°C/min)			15	
Cooling rate (°C/min)	-	-	1.5	
Surface flatness (µm) < 25		25		
Vacuum		4 independent zones (4", 6", 8", 12"), electronically controlled		
Electrical surface <sup>b</sup>		Grounded		

a. Other temperature ranges available upon request

b. Other electrical surface options available upon request: floating, triaxial





TOP VISION SYSTEM		
Option name	VHD	
X, Y, Z axis travel range (mm)	48	
X, Y axis displacement/revolution (mm)	1.41	
Z axis displacement/revolution (mm)	0.3175	
Magnification (X)	10	
Numerical aperture	0.28	
Depth of field (µm)	3.6	
Field of view (µm)	2.4	
Working distance (mm)	34	

Illumination type	In-line through video microscope unit, LED illuminator
Wavelength	Visible
Sensor type	Color, 12 bit, global shutter
Maximum frame rate (fps)	144
Resolution (MP)	2.9

SIDE VISION SYSTEM	
Mechanical positioning	Magnetic toggleable base, 6D manual coarse adjustment, XY manual translation stage
X - Y axis travel range (mm)	48
X - Y axis displacement/revolution (mm)	1.41
Magnification (X)	3
Numerical aperture	0.093
Field of view (mm)	2.9 x 2.2
Working distance (mm)	65
Wavelength range	Visible
Resolution (MP)	2.9
Frame rate (fps)	144
Sensor format (")	2/3
Sensor type	Color, 12 bit, global shutter
Wavelength	Visible



## **Optical head options**

OPTICAL HEAD PRO-P60		
Option name	PRO-P60	
Degrees of freedom	6 motorized	
Motor type	Piezo, hexapod	
X axis travel (mm)	20	
Y axis travel (mm)	11	
Z axis travel (mm)	20	
X,Y, Z axis resolution (nm)	1	
X,Y, Z axis uni-directional repeatability (nm)	50	
Rx axis travel (degree)	23	
Ry axis travel (degree)	38	
Rz axis travel (degree)	26	
Rx, Ry, Rz axis resolution	0.04 arcsec; 0.00001 °	
Rx, Ry, Rz axis uni-directional repeatability	1.5 arcsec; 0.0004 °	
Included	Rail system for toggling into engaged/disengaged positions, fiber array holder and single fiber holder	
Possible Orientations	North/East/West/South	
a. Other optical head options available upon request		

ELECTRICAL HEAD			
Option name	PRE-00	PRE-MO	
Translation stages type	Manual	Motorized XYZ, manual probe angle	
X , Y, Z axis travel range (mm)	48	25	
X , Y, Z axis resolution (nm)		200	
X , Y, Z axis repeatability (μm)		1.25	
X, Y, Z axis accuracy (µm)	Typical: 2	2.5	
X, Y, Z axis speed (mm/s)	-	0.4	
X, Y, Z axis displacement / revolution (mm/rev)	0.3	-	
Tilt travel (degree)	1	0	
Rail system X travel (mm)	180		
Z coarse step travel (mm)	Min: 6.35 Max: 56	Min: 6.35 Max: 57	
Possible orientations	North/East/West/South		



MAIN STATION SYSTEM	
Size (H x W x D)	1496 mm X 1448 mm x 1448 mm
Mass (kg)	1250
Operating temperature (°C)	18 - 22
Storage temperature (°C)	0 - 40
Operating humidity (RF)	20% - 60%
Storage humidity (RF)	10% - 70%, non-condensing
Base	Enclosed base system Granite base for passive vibration isolation Front doors and removable front optical breadboard for wafer loading
Optical breadboard	Grid of M6 threaded mounting holes 25 mm hole spacing Black anodized for reduced reflections
Workstation computer	4U rackmount industrial, Intel i7 CPU, 64 Gb RAM DDR5, 1Tb SSD, Nvidia RTX 4060 GPU, 3 Ethernet ports (10 + 2.5 +1 Gbit/s), multiple USB ports, additional PCIe slots, Windows 11 Pro, mouse and keyboard included
Monitors	2 x 27-in
Additional communication ports on base station for equipment	Ethernet Cat6 RJ54, USB-A 3.0
Cables, power supply, drive, controllers	All included

a. The system should be positioned in a low-vibration environment. Excessive floor or acoustical vibration can affect system performance. Although the base of the station includes a passive vibration isolation system, the expected vibration level for the operation of the OPAL-EC should be equal to or below the VC-A vibration criteria curve for edge-coupling alignment. The velocity should be below 50 (µm/s), when measured by the one-third octave bands of frequency over 8 to 80 Hz. At this level, vibrations are not perceptible. Else, contact us for more information on an active vibration damping system.

b. If at any time the operating temperature deviates from 20 °C, degradation in performance could occur



ORDERING INFORM	IATION	
Probe station	<b>Chuck option</b> 200 = 200 mm travel range for 8-in wafer 300 = 300 mm travel range for 12-in wafer TA = Ambient temperature (no temperature control) TA = Ambient - 200°C temperature control (heating only) TCH = 0°C - 200°C temperature control (heating and cooling}	
	Example: OPAL-EC-300-TCH	
DRDERING INFORM	ΙΑΤΙΟΝ	
Optical probe arm	PRO-XX	
	Probe arm grade P60 = 6 degrees of freedom motorized	
	Example: PRO-P60	
ORDERING INFORM	IATION	
Electrical probe arm	PRE-XX Probe arm grade 00 = Manual translation stage M0 = Motorized XYZ, manual probe angle	
	Example: PRE-MO	

As EXFO continuously improves its products, the delivered station may differ slightly from the one shown in the CADs and images used throughout this document.

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